編號: 200

國立成功大學九十七學年度碩士班招生考試試題

共 之 頁,第 []

系所: 電機工程學系甲組

科目:電子材料概論

本試題是否可以使用計算機:

□可使用 , □不可使用

(請命題老師勾選)

考試日期:0301, 節次:2

- 1. Calculate the Atomic Packing Factor (APF) for the diamond cubic structure (10%)
- 2. Calculate the minimum radius ratio for a coordination number of 8 (10%)
- 3. List the members of the <110> family of directions in the cubic system. (10%)
- 4. For low concentration of Zn in Cu, the diffusion coefficient of Zn has been measured to be 3.67x10⁻¹¹ cm²/s at 1000K and 8.32 x 10⁻¹⁸ cm²/s at 600K. Determine the activation energy for this process and then determine the value of the diffusion coefficient at 450K. (10%)
- 5. Fig.(1) shows a hypothetical binary eutectic phase diagram on which we indicate an alloy of composition 0.27B. Calculate the following quantities (20%)
 - a. The fraction of primary solid that forms under equilibrium cooling at the eutectic temperature .
 - b. The fraction of liquid with the eutectic composition that will transform to two solid phases below the eutectic isotherm
 - c. The amount of α and β that will form from the liquid just below the eutectic isotherm.
 - d. The total amount of phase in the alloy at a temperature just below the eutectic temperature.
- 6. Calculate the electrical resistivity of intrinsic silicon at 300K. For Si at 300K n=1.5x10¹⁶ carries/m³, q=1.6x10⁻¹⁹C, μ_n =0.135m²(V.s), and μ_0 =0.048m²(V.s) (10%)
- 7. A n-type Si wafer has been doped uniformly with 10^{16} antimony (Sb) atom/cm³. Calculate the position of the Fermi energy with respect to the Fermi energy E_{Fi} in intrinsic Si. The above n-type Si sample is further doped with $2x10^{17}$ boron atom/cm³. Calculate the position of the Fermi energy with respect to the Fermi energy E_{Fi} in intrinsic Si. (Assume that T=300K, and kT=0.0259eV) (10%)
- 8. Please explain or define following noun: (20%)
 - a). Frenkel defect
 - b). Schottky defect
 - c). Dislocation
 - d). Gibbs phase rule
 - e). Eutectic reaction
 - f). Index of refraction
 - g). Fluorescence
 - h). Phosphorescence

(背面仍有題目,請繼續作答)

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- i). Ferromagnetism
- j). Anti-ferromagnetism

Fig.(1)

